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**CHARACTERIZATION OF HIGH FREQUENCY OSCILLATOR AND
VARACTOR DIODES GROWN BY MOLECULAR BEAM EPITAXY**

by

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DISSERTATION

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**APPROVED BY
DISSERTATION COMMITTEE:**

This work is dedicated to my family for their loving support and encouragement

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This work addresses the output power optimization of semiconductor based submillimeter wavelength power sources. This wavelength region, from 1 mm to 100 μm (300 GHz to 3 THz), is of great importance in such applications as space-borne radio astronomy, spectroscopy, plasma diagnostics, and atmospheric remote sensing. Two candidate devices were investigated for their potential as submillimeter wavelength power sources: the double barrier resonant tunneling diode (DBRTD) and the heterojunction barrier varactor (HBV) diode. A reproducible molecular beam epitaxial growth process for AlAs/GaAs and AlAs/ $\text{In}_{0.53}\text{Ga}_{0.47}\text{As}$ devices was developed. The effect of a growth interruption at the DBRTD hetero-interface was studied and shown not to have a significant effect on the electrical characteristics. Furthermore, interface roughness at the normal and inverted interfaces was not found to play a significant role in determining high current density DBRTD transport characteristics.

The DBRTD oscillator output power is proportional to the $\Delta V \Delta J$ power density product where ΔV is the difference between the peak and valley voltage and ΔJ is the difference between the peak and valley current density. To increase ΔV , the downstream spacer layer profile is modified to take advantage of space-charge effects arising from carriers traversing a space-charge region at a constant

saturation velocity. Such a layer modification results in the Quantum Well Injection Transit (QWITT) diode. To increase ΔJ , devices should be fabricated in the AlAs/In_{0.53}Ga_{0.47}As material system which offers the highest ΔJ possible. Record DC-to-RF continuous wave conversion efficiencies of 52% and output powers of 20 mW, the highest reported for DBRTD oscillators, were achieved with AlAs/In_{0.53}Ga_{0.47}As QWITTs.

HBV diodes intended as submillimeter-wavelength frequency multipliers were also studied. HBV diodes in the AlAs/In_{0.53}Ga_{0.47}As and AlGaAs/GaAs material system were investigated. The current transport in these structures was analyzed and record breakdown voltages as high as 12 volts were achieved. This result represents a significant breakthrough for the application of HBV diodes.

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